



Solid state reactions in highly dispersed single and mixed lanthanide oxide–SiO₂ systems

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ABSTRACT

This paper summarizes our previous studies on the interaction of highly dispersed lanthanide oxides (La, Ce, Pr, Nd and Lu) with amorphous silica and presents new data on the Ce_{0.5}Yb_{0.5}O_{1.75}–SiO₂ system. It is shown that at temperatures above 800 °C, chemical reaction between lanthanide oxide and silica may occur leading to formation of silicate phases with unusual structure not observed for bulk like oxide–SiO₂ systems. For nano Ce_{0.5}Yb_{0.5}O_{1.75}–SiO₂ system results of TEM, SEM and XRD studies revealed that at or above 1000 °C, ytterbium is withdrawn from the mixed oxide and B-type polymorph of Yb₂Si₂O₇ (Yb₄[Si₃O₁₀][SiO₄]) is formed. This polymorph, till now known as high pressure form, is unstable at 1100 °C and transforms into ordinary C-type Yb₂Si₂O₇. Mechanism of silicate formation and its possible role in deactivation of supported catalysts containing lanthanide oxides as active phase or as promoters is discussed.

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1. Introduction

Highly dispersed lanthanide oxides play important role in various fields of modern technology. In catalysis they are often used as active components or as promoters, as for example in alumina supported noble metal catalysts used as three way converters of car exhaust gas. In such systems one of lanthanide dopant roles is stabilization of γ -Al₂O₃ support against sintering and hindering a phase transformation into α -Al₂O₃ (corundum). Mechanism of the stabilization involves strong interaction of lanthanide ions with alumina surface with formation of a surface compound [1]. Relatively less is known on the interaction of lanthanide oxides with the silica support, though such systems were studied as catalysts active e.g. in alpha-pinene isomerization (La, Pr, Sm, Eu, Tb, and Yb) [2] or in TWC process (Pd/CeO₂–SiO₂) [3].

Existing literature shows that at elevated temperatures solid state reaction between lanthanide oxide and high area silica occurs with formation of silicates. This process drastically changes the microstructure of the system and clearly influences the catalytic activity of lanthanide ions (e.g. as reversible change of the oxidation state) [4,5]. Analysis of lanthanide oxide–SiO₂ binary diagrams

reveals that silicates with various stoichiometry can be formed: Ln₂SiO₅ (Ln₂O₃:SiO₂ = 1:1), Ln_{9.33}Si₆O₂₆ (7:9) and Ln₂Si₂O₇ (1:2) [6–8]. Moreover, extensive polymorphism of Ln₂Si₂O₇ occurs, with nine polymorphic forms (A, B, C, D, E, F, G, H, I) observed depending on lanthanide ion radius and temperature [6,9–11]. Below 1500 °C at normal pressure, A-, B- and C-type of structures are typical for light, medium and heavy lanthanide ions, respectively, while at higher temperatures D-, E-, F- or G-types are stable [6,9]. Under high pressure conditions, new structures called X, K and L have been found [12–14].

Recent studies on highly dispersed lanthanide oxides deposited on high surface SiO₂ revealed that surface silicates with unexpected I- and B-type structure form for La [15], Pr [5], Nd [16] and Lu [4] at low temperature (<1100 °C). Both I and B-type are not “real” disilicates, because they do not have [Si₂O₇]^{–6} groups in the structure. Their correct structure formula are: Ln₆[Si₄O₁₃][SiO₄]₂ for I-type (observed for La–Nd) and Ln₄[Si₃O₁₀][SiO₄] for B-type (observed for heavy lanthanides). At higher temperatures I- and B-type of silicates transform into usual A- and C-type, respectively.

To our best knowledge there is no data in the literature on the interaction of mixed lanthanide oxides with high surface silica. There are however, few works devoted to mixed lanthanide oxides Ce_{1–x}Tb_xO_{2–y}, [17,18] or Ce_{1–x}Pr_xO_{2–y} [19,20] on alumina or La modified alumina. It has been found that stability of nanocrystalline mixed oxides (4–16 nm) supported on alumina

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depends on temperature and atmosphere of thermal treatment. In reducing atmosphere, perovskite phase LnAlO_3 ($\text{Ln} = \text{Ce}, \text{Pr}$ or Tb) was observed after heating at 900°C [17,19,20]. In contrast, $\text{Ce}_{0.8}\text{Tb}_{0.2}\text{O}_{2-y}$ mixed oxide supported on modified alumina surface appeared to be stable at temperature up to 900°C in oxidizing and inert atmosphere [17,18].

In this work, the microstructure and thermal stability of a new $\text{Ce}_{0.5}\text{Yb}_{0.5}\text{O}_{1.75}-\text{SiO}_2$ system, was studied at temperatures up to 1100°C in air. The main goal was observation of possible chemical reactions between nanocrystalline mixed oxide and silica support that could lead to segregation of the oxide components and formation of surface silicates. Samples subjected to various treatments were thoroughly characterized by XRD, TEM, SEM-EDS and FTIR. Results obtained are compared with earlier data on structural stability of single $\text{LnO}_x-\text{SiO}_2$ systems ($\text{Ln} = \text{La}, \text{Ce}, \text{Pr}, \text{Nd}, \text{Lu}$).

2. Materials and methods

$\text{LnO}_x-\text{SiO}_2$ samples were prepared by impregnation of a high surface silica with an aqueous solution of lanthanide nitrate ($\text{La}, \text{Nd}, \text{Yb}$ and Lu) [4,15,16] or with a suspension of nano-oxide ($\text{CeO}_2, \text{PrO}_x, \text{Ce}_{0.5}\text{Yb}_{0.5}\text{O}_{1.75}$). 20 wt% colloidal suspension of CeO_2 (Aldrich Product No. 28.924-4) or a suspension of an amorphous PrO_x oxide precursor in methanol was used [5,21]. $\text{Ce}_{0.5}\text{Yb}_{0.5}\text{O}_{1.75}-\text{SiO}_2$ samples were synthesized as follows. First nanoparticles of $\text{Ce}_{0.5}\text{Yb}_{0.5}\text{O}_{1.75}$ were prepared by W/O (water-in-oil) microemulsion method [5]. Then, as-prepared, dense suspension of the oxide in organic phase was washed several times with distilled water to remove the surfactant. Finally, small amount of acetic acid (to $\text{pH} \approx 4$) was added to create a stable dispersion. High surface silica (Degussa OX-130, $S_0 = 170 \text{ m}^2/\text{g}$) was impregnated with the dispersion to get $\text{Ce}_{0.5}\text{Yb}_{0.5}\text{O}_{1.75}-\text{SiO}_2$ sample with a molar ratio $\text{SiO}_2:\text{Ce}_{0.5}\text{Yb}_{0.5}\text{O}_{1.75} = 14:1$. After drying at 120°C overnight, the sample was pre-heated at 550°C for 3 h in oxygen flow to clean out organic residues and remaining nitrate groups. Such standardized sample (called “as-prepared”) was heated at temperatures from 800 to 1100°C in static air.

Phase composition and lattice parameter of the samples were determined by XRD (PANalytical X'Pert PRO X-ray powder diffractometer, $\text{Cu K}\alpha$ radiation) with FullProf program [22] used for display and analysis of the diffractograms. Morphology and microstructure was investigated by TEM (Philips CM-20 SuperTwin operating at 200 kV and providing 0.25 nm resolution). HRTEM images and SAED patterns were analysed with DigitalMicrograph program. JEMS program was used for simulation of HRTEM images. Uniformity and chemical composition of the samples was checked with FE-SEM microscope (FEI NovaNanoSEM 230) equipped with EDS analyzer (EDAX Genesis XM4).

3. Results and discussion

3.1. Single lanthanide oxide-silica

Morphology and phase evolution of highly dispersed $\text{LnO}_x-\text{SiO}_2$ systems upon thermal treatment has been described in our previous papers for La [15], Ce [21], Pr [5], Nd [16] and Lu [4]. Morphology of the as-prepared samples (i.e., after pretreatment in air at 550°C) was closely related to the synthesis procedure. Well-defined crystalline particles of CeO_2 [21] or Pr_6O_{11} [5] with mean size of ca. 5 nm were present in the samples obtained by impregnation of SiO_2 with suspension of oxide nanoparticles. In contrast, no distinct lanthanide oxide phase was formed in the samples prepared by impregnation of the support with an aqueous solution of La - [15] and Nd - [16] nitrates. Instead formation of a nanometer thick amorphous layer of $\text{Ln}_x\text{Si}_y\text{O}_z$ silicate on the silica surface was observed.

For silica impregnated with Lu nitrate both amorphous silicate and nanocrystalline Lu_2O_3 were observed [4]. In this case, however, high surface coverage of silica with lanthanide was used, resulting probably in formation of three dimensional aggregates of nitrate not in direct contact with silica surface.

As the result of heat treatment decrease of the surface area of Ln_2O_3 -silica systems was observed. For $\text{La}_2\text{O}_3-\text{SiO}_2$ obtained by impregnation of high surface SiO_2 (Degussa OX-130) with an aqueous solution of La nitrate the BET surface area (calculated per gram of the support) decreased from $150 \text{ m}^2/\text{g}$ at 600°C to $60 \text{ m}^2/\text{g}$ at 1100°C . Up to 950°C only slight ($\sim 30 \text{ m}^2/\text{g}$) decrease but then at 1000°C rapid loss of the surface area occurred. This behavior reflected generally the loss of surface area of the bare silica support: decrease from 170 to $160 \text{ m}^2/\text{g}$ between 600 and 950°C and then surface loss to 119 and $71 \text{ m}^2/\text{g}$ at 1000 and 1100°C , respectively [15].

Annealing of nanocrystalline CeO_2 supported on SiO_2 in oxidizing atmosphere at temperatures up to 1100°C , caused only crystallite growth of CeO_2 and sintering of the silica support [21]. CeO_2 crystals often assumed spherical shape, probably to minimize $\text{CeO}_2-\text{SiO}_2$ interface. No solid state reaction between ceria and silica was detected, presumably because Ce^{4+} ions cannot be reduced under such conditions to Ce^{3+} ions found in all known Ce silicates [23]. An exception is CeSiO_4 that however, forms only at hydrothermal conditions [24]. In accordance with this fact, formation of various Ce silicates was observed for $\text{CeO}_2-\text{SiO}_2$ systems heated in reducing atmosphere [25–27]. In literature, absence of $\text{CeO}_2-\text{SiO}_2$ reaction in oxidizing atmosphere up to 1200°C was also reported in [28–31], whereas cerium silicates were observed in reducing atmosphere [32,33].

Different behavior was found for Pr_6O_{11} nanocrystals deposited on silica surface [5]. Already after heating at 800°C in air, partial amorphization and spreading of the oxide was observed by XRD and HRTEM. At 950°C an amorphous praseodymium silicate formed, which then at 1000°C crystallized into unusual I type $\text{Pr}_2\text{Si}_2\text{O}_7$. For $\text{LnO}_x-\text{SiO}_2$ prepared by impregnation I-type silicates crystallized already at 950°C for La [15] and Nd [16]. In line with our results, formation of an amorphous Ln-silicate at $800-900^\circ\text{C}$, with no intermediate Ln oxide phase was reported for high surface silica impregnated with $\text{La}, \text{Pr}, \text{Sm}, \text{Eu}, \text{Tb}$, and Yb nitrates [2,34,35]. Amorphous or poorly ordered lanthanide silicates were also observed below 1000°C in $\text{LnO}_x-\text{SiO}_2$ systems prepared by sol-gel, deposition-precipitation or vacuum evaporation [36–38].

After treatment at 1000°C or higher, crystalline lanthanide silicates of various structure were observed in all $\text{LnO}_x-\text{SiO}_2$ systems studied by us, regardless of preparation method (Table 1). For light Ln^{3+} -ions ($\text{La}, \text{Pr}, \text{Nd}$) [5,15,16], I-type $\text{Ln}_2\text{Si}_2\text{O}_7$ silicates (proper formula $\text{Ln}_6[\text{Si}_4\text{O}_{13}][\text{SiO}_4]_2$) occurred at the lowest temperature. Then, with increasing temperature, this phase transformed into A-type $\text{Ln}_2\text{Si}_2\text{O}_7$ (structure formula $\text{Ln}_2[\text{Si}_2\text{O}_7]$). For heavy Ln^{3+} -ions (Yb, Lu) [4, this work] B-type silicate (proper formula $\text{Lu}_4[\text{Si}_3\text{O}_{10}][\text{SiO}_4]$) occurred as the first crystalline phase which, at higher temperatures, transformed into C-type structure (structure formula $\text{Ln}_2[\text{Si}_2\text{O}_7]$).

Formation of oligosilicates $\text{Ln}_6[\text{Si}_4\text{O}_{13}][\text{SiO}_4]_2$ (I-type) and $\text{Ln}_4[\text{Si}_3\text{O}_{10}][\text{SiO}_4]$ (B-type) for light ($\text{La}, \text{Pr}, \text{Nd}$) and heavy (Lu, Yb) lanthanides at temperatures between 1000°C and 1100°C was unexpected in view of classic phase diagram presented by Felsche [9] (Fig. 1). However, other authors also reported that under special conditions such oligosilicates may occur for La [11], Lu, Yb and Tm [12,39].

3.2. Mixed lanthanide oxide-silica

EDX analysis of a dried dispersion of $\text{Ce}_{0.5}\text{Yb}_{0.5}\text{O}_{1.75}$ nanoparticles used for preparation of the mixed oxide-silica

Table 1
Crystalline silicate phases identified in various LnO_x-SiO₂ samples heated in air.

Temp.	La (Imp) ^a [15]	Ce (NP) ^a [21]	Pr (NP) [5]	Nd (Imp) [16]	Lu (Imp) [4]	Ce _{0.50} Yb _{0.50} (NP)[this work]
950 °C	I	Oxide	I	I	Oxide	Oxide
1000 °C	I	Oxide	I	I	B	B
1100 °C	I	Oxide	I or/and A	I	B	B or/and C
1200 °C	A	Oxide	-	A	C	-

^a Sample prepared by impregnation with aqueous solution of Ln nitrate or with dispersion of nanoparticles, respectively.

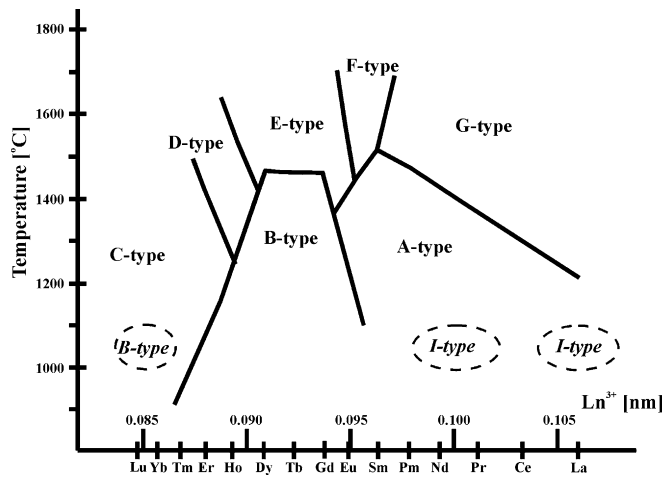


Fig. 1. Stability range of silica rich lanthanide silicates (Ln₂O₃ + 2SiO₂) according to [9]. New I- and B-type structures obtained at low temperatures are included.

sample confirmed an assumed chemical composition of the oxide (Ce/Yb=1/1). Fig. 2 shows TEM and HRTEM images of Ce_{0.50}Yb_{0.50}O_{1.75}-SiO₂ after pre-treatment at 550 °C for 3 h in oxygen flow. It is seen that the mixed oxide is homogeneously distributed on SiO₂ surface as individual crystallites or small clusters of crystallites. Particle size distribution measured from TEM micrographs (inset to Fig. 2) is relatively narrow with mean particle size of 2.2 nm. Lattice fringes with 0.32 nm spacing seen on the particles, correspond to (2 2 2)_C planes of Ce_{0.50}Yb_{0.50}O_{1.75} with C#-type (defected C-type) cubic structure. This observation was confirmed by XRD pattern (Fig. 3b), where wide reflections at positions (~20°) of amorphous silica occurred. Generally, morphology of the sample resembled that seen for CeO₂ and Pr₆O₁₁ nanoparticles supported on silica [5,21]. Thermal stability of the “as prepared” sample was then studied by observation of structure change upon heat

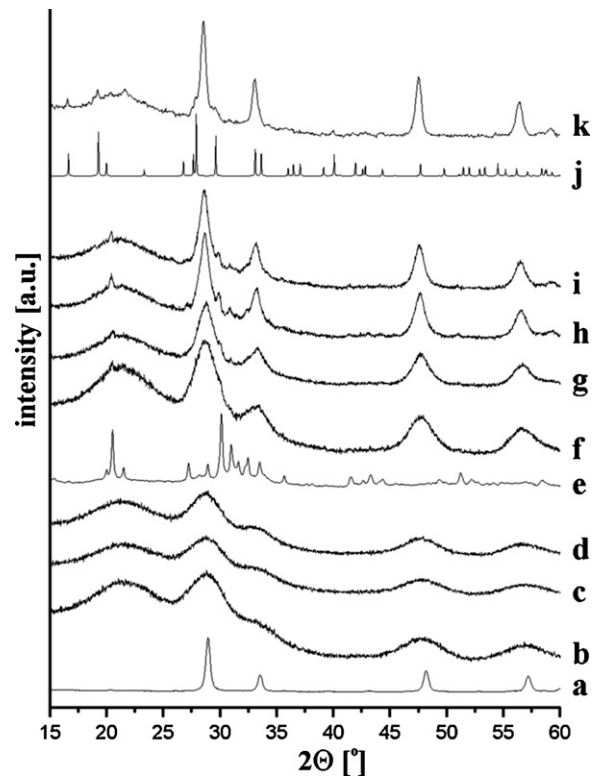


Fig. 3. XRD diffractograms of Ce_{0.50}Yb_{0.50}O_{1.75}-SiO₂ sample subjected to various heat treatment. (a) Unsupported Ce_{0.50}Yb_{0.50}O_{1.75}, (b) 550 °C/3 h O₂, (c) 800 °C/3 h air, (d) 900 °C/3 h air, (e) B-type Yb₂Si₂O₇ standard, (f) 1000 °C/3 h air, (g) 1040 °C/3 h air, (h) 1080 °C/3 h air, (i) 1100 °C/3 h air, (j) C-type Yb₂Si₂O₇ standard, (k) 1100 °C/28 h air.

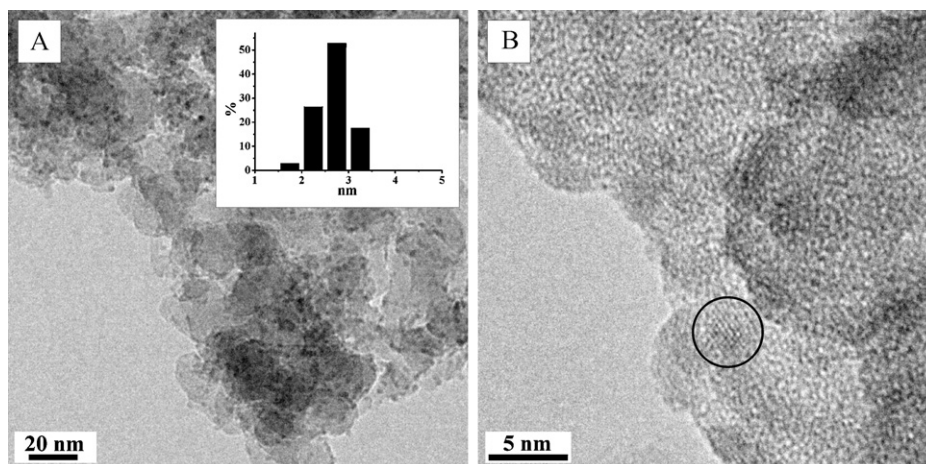


Fig. 2. TEM (A) and HRTEM (B) images of Ce_{0.50}Yb_{0.50}O_{1.75}-SiO₂ sample after heating at 550 °C for 3 h in O₂. Crystallite size distribution is included as inset to A.

treatment at 800, 900, 1000, 1020, 1040, 1060, 1080 and 1100 °C in static air. Results of the XRD and HRTEM experiments are summarized in Table 2.

Both XRD and TEM revealed high structure stability of the mixed oxide on silica up to 900 °C. In XRD diffractograms (Fig. 3 trace c and d) hardly any change can be seen in widths and positions of the reflections. Lattice parameter of $\text{Ce}_{0.50}\text{Yb}_{0.50}\text{O}_{1.75}$ determined from traces b, c and d was $a_F = 1/2 a_C = \sim 0.535$ nm and mean crystallite size was ~ 2 nm. TEM and SAED images of the $\text{Ce}_{0.50}\text{Yb}_{0.50}\text{O}_{1.75}\text{-SiO}_2$ sample after heating at 800 °C are shown in Fig. 4. In the SAED pattern obtained from a large area rings visible at $d = 0.32, 0.27, 0.23, 0.19, 0.16$ and very weak 0.44 nm, correspond to $(222)_C, (400)_C, (332)_C, (440)_C, (622)_C$ and $(211)_C$ planes of $\text{Ce}_{0.50}\text{Yb}_{0.50}\text{O}_{1.75}$ (cubic C#-type structure), respectively. This result agrees with our earlier study on unsupported Yb-doped ceria, where it was shown that depending on composition the structure of the oxide can be described as defected cubic F or C-type [40]. In HRTEM micrographs (e.g. Fig. 4B) $\text{Ce}_{0.50}\text{Yb}_{0.50}\text{O}_{1.75}$ crystallites could be identified as areas exhibiting 0.32 nm lattice fringes corresponding to $(222)_C$ planes. Mean crystallite size determined from HRTEM (3.5 nm) was higher than that measured from XRD (2.2 nm). The difference could be due to large lattice strain contribution to the peaks broadening in XRD.

The first signs of a solid state reaction between the mixed oxide and the silica occurred in the sample heated at 1000 °C for 3 h. In XRD pattern of this sample (Fig. 3f) very weak peak, characteristic for triclinic of $\text{Yb}_2\text{Si}_2\text{O}_7$ (PDF File nr. 00-030-1439), appeared at 20.4° . Intensity of the peaks characteristic for this silicate enhanced with increasing temperature up to 1100 °C. The triclinic $\text{Yb}_2\text{Si}_2\text{O}_7$ appears to be isostructural with B-type Tm and Lu silicates [4,39,41], but till now was observed only at high pressure [39]. In order to explain this inconsistency we tried to synthesize B-type $\text{Yb}_2\text{Si}_2\text{O}_7$ at normal pressure by thermal treatment of a high surface silica impregnated with Yb nitrate, according to the procedure used previously for Lu [4]. Fig. 5A (red dots) shows XRD pattern of the sample heated at 1000 °C for 3 h, together with the result of structure refinement performed with FullProf [22]. As a starting mode for the refinement the structure of B-Tm $_2\text{Si}_2\text{O}_7$ was used [41]. Due to complex background caused by the presence of an amorphous phase accuracy of the refinement was not good enough to enable determination of all atomic parameters. It appears, however that there is reasonable fit between experimental and calculated patterns, what proves that the structure model applied was correct. Unit cell parameters refined for the silicate are given in Table 3. Further evidence for the presence of B-type $\text{Yb}_2\text{Si}_2\text{O}_7$ has been obtained from FTIR spectrum (Fig. 5B), which contains bands at 693 and 723 cm^{-1} , characteristic for $[\text{Si}_3\text{O}_{10}]$ groups [4]. Above results indicate that under normal pressure conditions, used to in this work, B-type $\text{Yb}_2\text{Si}_2\text{O}_7$ may form also in $\text{Ce}_{0.50}\text{Yb}_{0.50}\text{O}_{1.75}\text{-SiO}_2$ system. Unit cell parameters measured for the sample heated at 1100 °C are similar to those measured for the impregnated sample (Table 3). Fig. 6 shows HRTEM image, with corresponding FFT pattern, of B-type $\text{Yb}_2\text{Si}_2\text{O}_7$ crystal in $[00\text{-}1]$ orientation found in the $\text{Ce}_{0.50}\text{Yb}_{0.50}\text{O}_{1.75}\text{-SiO}_2$ heated at 1080 °C. Good correspondence between the observed HRTEM image and that simulated using the crystal structure determined by Rietveld refinement (inset to Fig. 6) also validates the proposed structure of the silicate.

Prolonged heating of $\text{Ce}_{0.50}\text{Yb}_{0.50}\text{O}_{1.75}\text{-SiO}_2$ at 1100 °C (28 h) caused gradual decline of the reflections of B-type $\text{Yb}_2\text{Si}_2\text{O}_7$ in XRD pattern and simultaneous appearance of reflections of monoclinic Ctype $\text{Yb}_2\text{Si}_2\text{O}_7$ (Fig. 3k), which is considered as thermodynamically stable polymorph at normal pressure and at low temperatures [9,12].

It is interesting to compare the behavior of the $\text{Ce}_{0.50}\text{Yb}_{0.50}\text{O}_{1.75}\text{-SiO}_2$ with that of Yb_2O_3 supported on silica. Yamamoto et al., in a series of papers [2,42,43], studied thoroughly

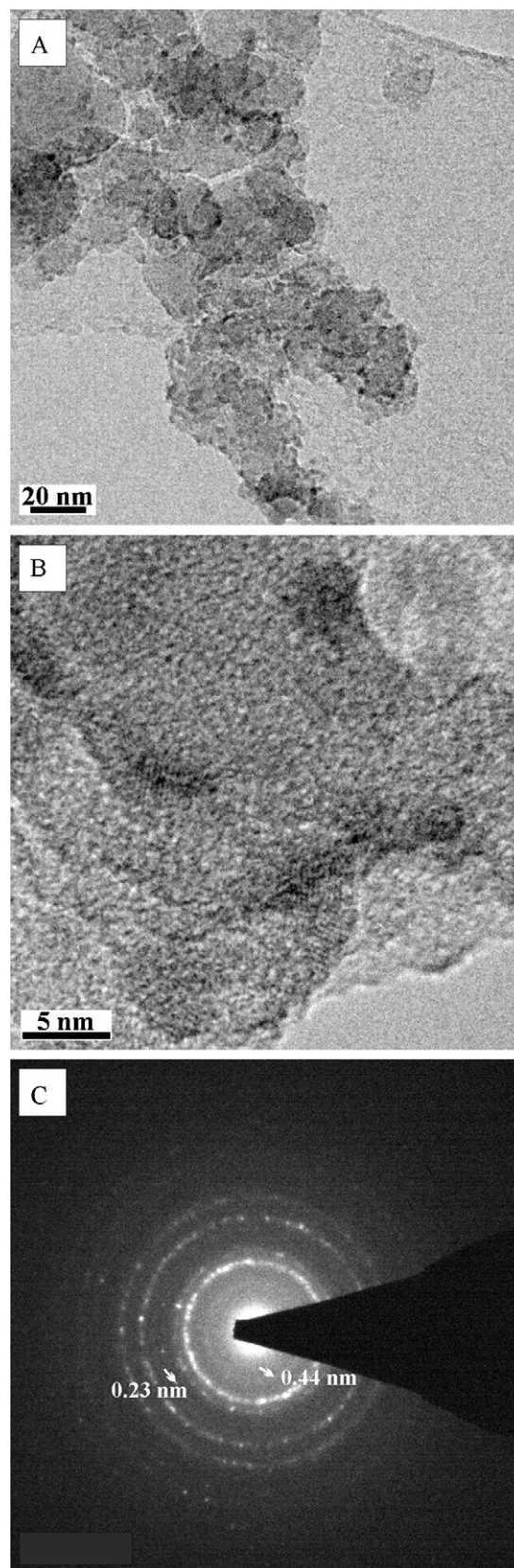


Fig. 4. TEM (A), HRTEM (B) images and SAED pattern (C) of $\text{Ce}_{0.50}\text{Yb}_{0.50}\text{O}_{1.75}\text{-SiO}_2$ sample heated at 800 °C for 3 h in air.

Table 2
Characterization of Ce_{0.50}Yb_{0.50}O_{1.75}-SiO₂ sample subjected to various treatments.

Treatment	Phases present	x	Lattice parameter (a _F) [nm]	Mean crystallite size	
				XRD [nm]	TEM [nm]
550 °C/3 h O ₂	SiO ₂ (a) Ce _{1-x} Yb _x O _{2-(x/2)} (c)	0.5(0.5) ^a	0.5352(0.5360) ^a	2.2(5.0) ^a	2.7[2–4]
800 °C/3 h air	SiO ₂ (a) Ce _{1-x} Yb _x O _{2-(x/2)} (c)	0.5(0.5) ^a	0.5345(0.5351) ^a	1.9(12.9) ^a	4.1[2–10]
900 °C/3 h air	SiO ₂ (a) Ce _{1-x} Yb _x O _{2-(x/2)} (c)	0.45(0.5) ^a	0.5362(0.5345) ^a	2.2(21.7) ^a	3.5[2–9]
1000 °C/3 h air	SiO ₂ (a) Ce _{1-x} Yb _x O _{2-(x/2)} (c) Yb ₂ Si ₂ O ₇ (B)	0.3	0.5379	3.2	3.9[2–9]
1020 °C/3 h air	SiO ₂ (a) Ce _{1-x} Yb _x O _{2-(x/2)} (c) Yb ₂ Si ₂ O ₇ (B)	0.25	0.5384	3.6	4.6[2–24]
1040 °C/3 h air	SiO ₂ (a) Ce _{1-x} Yb _x O _{2-(x/2)} (c) Yb ₂ Si ₂ O ₇ (B)	0.2	0.5396	4.2	5.6[2–19]
1060 °C/3 h air	SiO ₂ (a) Ce _{1-x} Yb _x O _{2-(x/2)} (c) Yb ₂ Si ₂ O ₇ (B)	0.15	0.5398	5.3	7[3–14]
1080 °C/3 h air	SiO ₂ (a) Ce _{1-x} Yb _x O _{2-(x/2)} (c) Yb ₂ Si ₂ O ₇ (B)	0.1	0.5400	6.2	7.3[3–26]
1100 °C/3 h air	SiO ₂ (a) Ce _{1-x} Yb _x O _{2-(x/2)} (c) Yb ₂ Si ₂ O ₇ (B)	0.1	0.5401	7.2	8.8[3–20]
1100 °C/28 h air	SiO ₂ (a) Ce _{1-x} Yb _x O _{2-(x/2)} (c) Yb ₂ Si ₂ O ₇ (B + C)	~0(0.5) ^a	0.5405(0.5343) ^a	12.3(53.4) ^a	–

a – amorphous; c – cubic structure; B – B-type of Yb₂Si₂O₇ (triclinic structure); C – C-type of Yb₂Si₂O₇ (monoclinic structure).

^a Results obtained for unsupported Ce_{0.50}Yb_{0.50}O_{1.75} mixed oxide after similar treatment [40].

the Yb₂O₃/SiO₂ catalysts obtained by impregnation of a high surface SiO₂ with an aqueous solution of Yb nitrate over wide range of Yb loadings up to 62 wt% Yb₂O₃. Basing on experimental data obtained with various methods (including XRD, EXAFS, Raman, BET and various chemical techniques) the authors claimed that up to the highest loading and calcination temperature up to 800 °C no crystalline phases were observed and Yb existed at the surface as individual YbO₆ octahedra strongly interacting with the silica surface. After calcination at 1000 °C, Raman spectra showed the appearance of new bands that the authors assigned to unidentified Yb silicate [2]. For Ce_{0.50}Yb_{0.50}O_{1.75}-SiO₂ formation of crystalline Yb silicate was also detected after heating at 1000 °C and we proved that the silicate is B-type polymorph of Yb₂Si₂O₇ reported in the literature as high pressure form [12,39]. The question is why, in contrast to the present observation, B-type Yb₂Si₂O₇ was previously observed only at high pressure and high temperature? In previous work [4], we showed that in similar highly dispersed Lu₂O₃-SiO₂ system the B-type Lu₂Si₂O₇ (Lu₄[Si₃O₁₀][SiO₄]) occurred after heating at 1000 °C and we presented arguments that this is in fact a preferred low temperature structure for all heavy lanthanides. However, due to kinetic limitations at low temperature, this polymorph cannot be obtained by classic ceramic route, i.e. direct solid state reaction between macroscopic, crystalline Ln₂O₃ (Ln = Tm, Yb and Lu) and SiO₂. Very high dispersion

of lanthanide over the high surface amorphous silica obtained via impregnation with nitrate solution or nanoparticle dispersion enables the intimate lanthanide-silica contact and decreases the reaction barrier.

Formation of ytterbium silicate as the result of a solid state reaction between Ce_{0.50}Yb_{0.50}O_{1.75} and SiO₂ requires a transfer of Yb³⁺-ions from the mixed oxide to the support. The depletion of the mixed oxide in Yb³⁺-ions manifested itself in XRD patterns as a shift the oxide reflections towards lower angles caused by continuous growth of the cell parameter from a_F = 1/2 a_C = 0.5352 nm (corresponding to Ce_{0.5}Yb_{0.5}O_{1.75} [40]) to a_F = 0.5405 nm (close to pure ceria) with increasing calcination temperature (Fig. 3). It is seen that in accordance with the proposed mechanism of Yb silicate formation in Ce_{0.50}Yb_{0.50}O_{1.75}-SiO₂ the amount of this phase formed at 1000 °C is very small, much smaller than in Yb₂O₃-SiO₂ sample subjected to identical heat treatment (cf. Figs. 3f and 5A). Morphology of particles of the mixed oxide strongly depleted in Yb differed dramatically from that of the silicate. In the samples heated above 1060 °C the oxide particles exhibited spherical shape with a mean size ~10 nm. Fig. 7 presents HRTEM image and microdiffraction pattern of such a particle in [1 1 0] orientation. The growth of spherical particles is correlated with severe sintering of the silica support above 1000 °C, which manifests itself as sudden decline of the specific surface area [15]. The spherical shape minimizes the

Table 3
Comparison of lattice parameters of B-type silicates (P -1 space group) identified in this work with literature data.

Sample	a [nm]	b [nm]	c [nm]	Alpha [°]	Beta [°]	Gamma [°]
Ce _{0.50} Yb _{0.50} O _{1.75} -SiO ₂ 1080 °C	0.656	0.663	1.201	94.01	91.58	92.01
Yb ₂ O ₃ -SiO ₂ 1000 °C	0.6530	0.6581	1.1915	94.36	91.28	92.09
Yb ₂ Si ₂ O ₇ PDF Card 00-030-1439	0.6530	0.6550	1.1890	94.28	91.15	91.75
B-type Tm ₂ Si ₂ O ₇ PDF Card 00-031-1391	0.6548	0.6576	1.1920	94.39	91.19	91.81

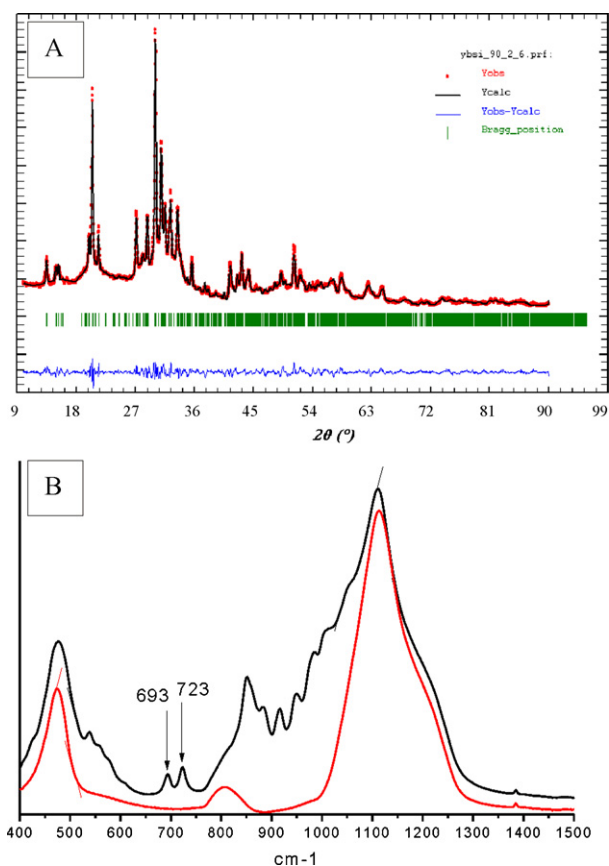


Fig. 5. Refinement of the structure of B-type $\text{Yb}_2\text{Si}_2\text{O}_7$ formed in Yb_2O_3 - SiO_2 sample heated at 1000°C for 3 h (A) and FTIR spectra of the sample (B).

interface surface area between the oxide particles and surrounding silica matrix. Overall morphology of the $\text{Ce}_{0.50}\text{Yb}_{0.50}\text{O}_{1.75}$ - SiO_2 sample heated at high temperatures is presented in SEM image (Fig. 8). The image, formed using back-scattered electrons (material contrast), shows both spherical particles of the oxide and irregular silicate crystallites uniformly distributed within the silica grains.

A positive effect of silica support on the structure stability of $\text{Ce}_{0.50}\text{Yb}_{0.50}\text{O}_{1.75}$ nanocrystals becomes apparent when results presented in this work are compared with those for the unsupported

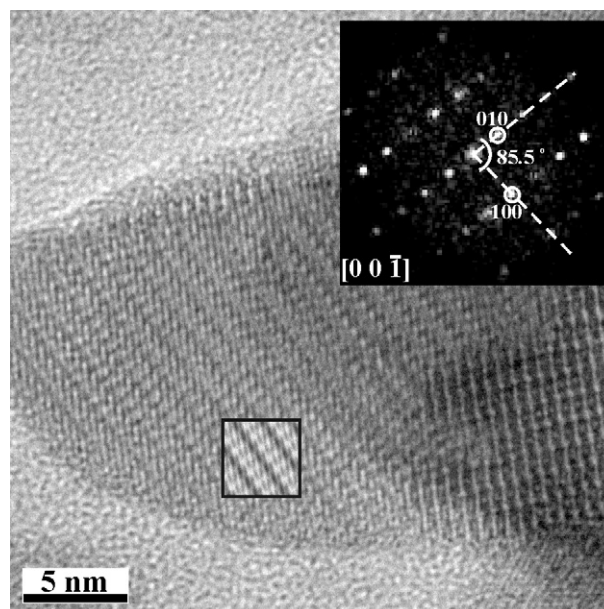


Fig. 6. HRTEM image, with corresponding FFT pattern, of B-type $\text{Yb}_2\text{Si}_2\text{O}_7$ crystallite. Simulated image is included as inset.

oxide [40]. As expected, sintering of the supported particles has been strongly restricted with hardly any growth of a mean crystallite size up to 900°C (Table 2). Under the same conditions mean crystallite size of the unsupported oxide increased four times. On the other hand, decomposition of the mixed oxide supported on silica was observed at or above 1000°C due to formation of ytterbium silicate, whereas the unsupported mixed oxide showed no evidence of the phase separation even after very long (45 h) thermal treatment at 1100°C [40]. It appears therefore, that high surface silica may be used as an inert support for nanocrystalline ceria doped with ytterbium (and possibly other lanthanides) only at temperatures up to 900°C . At higher temperatures adverse effects (oxide decomposition due to formation of silicates and severe sintering of silica) probably preclude usage of silica as catalytic support. It should be mentioned also that in reducing atmosphere such adverse effects may occur at much lower temperatures (above 700°C) due to possible formation of cerium silicates [25–27,32,33].

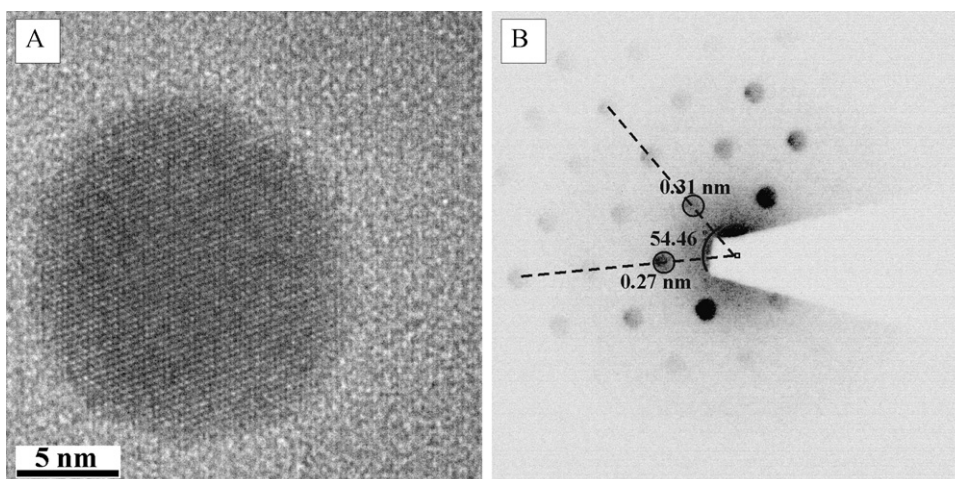


Fig. 7. HRTEM image (A) and microdiffraction pattern (B) of a spherical Yb depleted oxide particle in silica matrix.

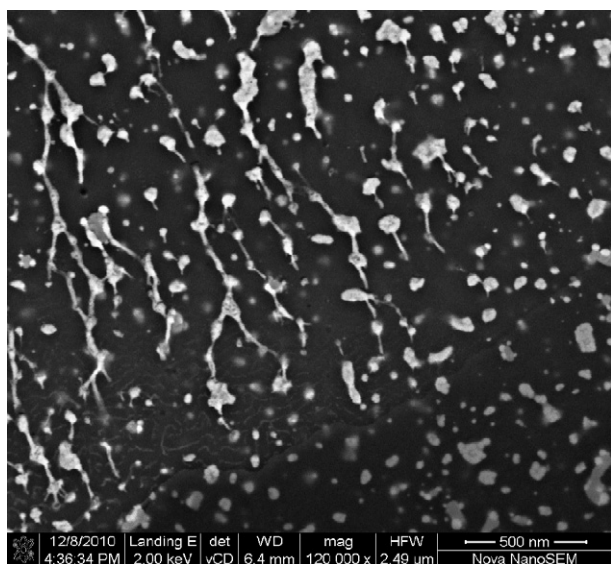


Fig. 8. SEM image of $\text{Ce}_{0.50}\text{Yb}_{0.50}\text{O}_{1.75}\text{-SiO}_2$ sample heated at 1100°C for 28 h in air.

4. Conclusions

Nanocrystalline $\text{Ce}_{0.50}\text{Yb}_{0.50}\text{O}_{1.75}$ mixed oxide ($\sim 2\text{ nm}$ mean particle size) prepared by microemulsion method was uniformly distributed over the surface of high surface SiO_2 from an aqueous suspension.

The nano-sized $\text{Ce}_{0.50}\text{Yb}_{0.50}\text{O}_{1.75}$ supported on silica exhibited very high textural and structural stability in air up to 900°C . At 1000°C decomposition of the supported oxide was observed, due to migration of Yb^{3+} -ions to silica and formation of ytterbium silicate.

The ytterbium silicate formed at 1000°C exhibited unusual, B-type $\text{Yb}_2\text{Si}_2\text{O}_7$ structure (proper formula $\text{Yb}_4[\text{Si}_3\text{O}_{10}][\text{SiO}_4]$), till now observed only at high pressure. At 1100°C this silicate slowly transformed into monoclinic C-type $\text{Yb}_2\text{Si}_2\text{O}_7$.

High surface silica may be used as an inert support for nanocrystalline ceria doped with ytterbium (and possibly other lanthanides) in oxidizing atmosphere at temperatures up to 900°C . At higher temperatures adverse effects (oxide decomposition due to formation of silicates and severe sintering of silica) occur. In reducing atmosphere such adverse effects may occur at much lower temperatures (above 700°C) due to possible formation of cerium silicates.

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